

Controllable Ordering of the Fractional Double Perovskite, EuTa_2O_6



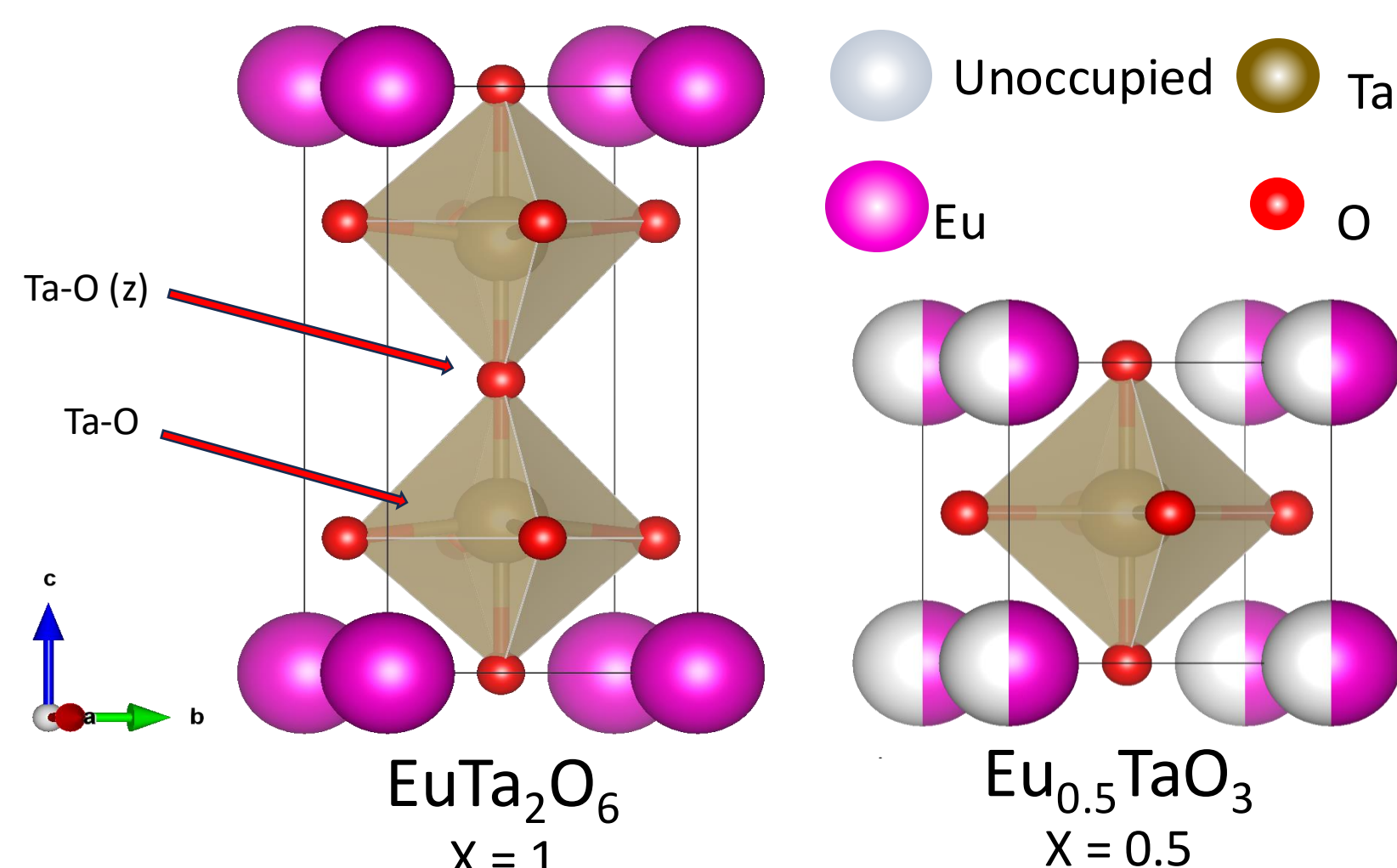
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Motivation: A-site ordering of the fractional double perovskite, EuTa_2O_6 , has shown to form a quasi-2D Electron Gas (quasi-2DEG) that is controllable by an external magnetic field.

Goal: Control over the amount of A-site ordering in the crystal structure during growth by Molecular Beam Epitaxy.

Structural features of fractional double perovskites



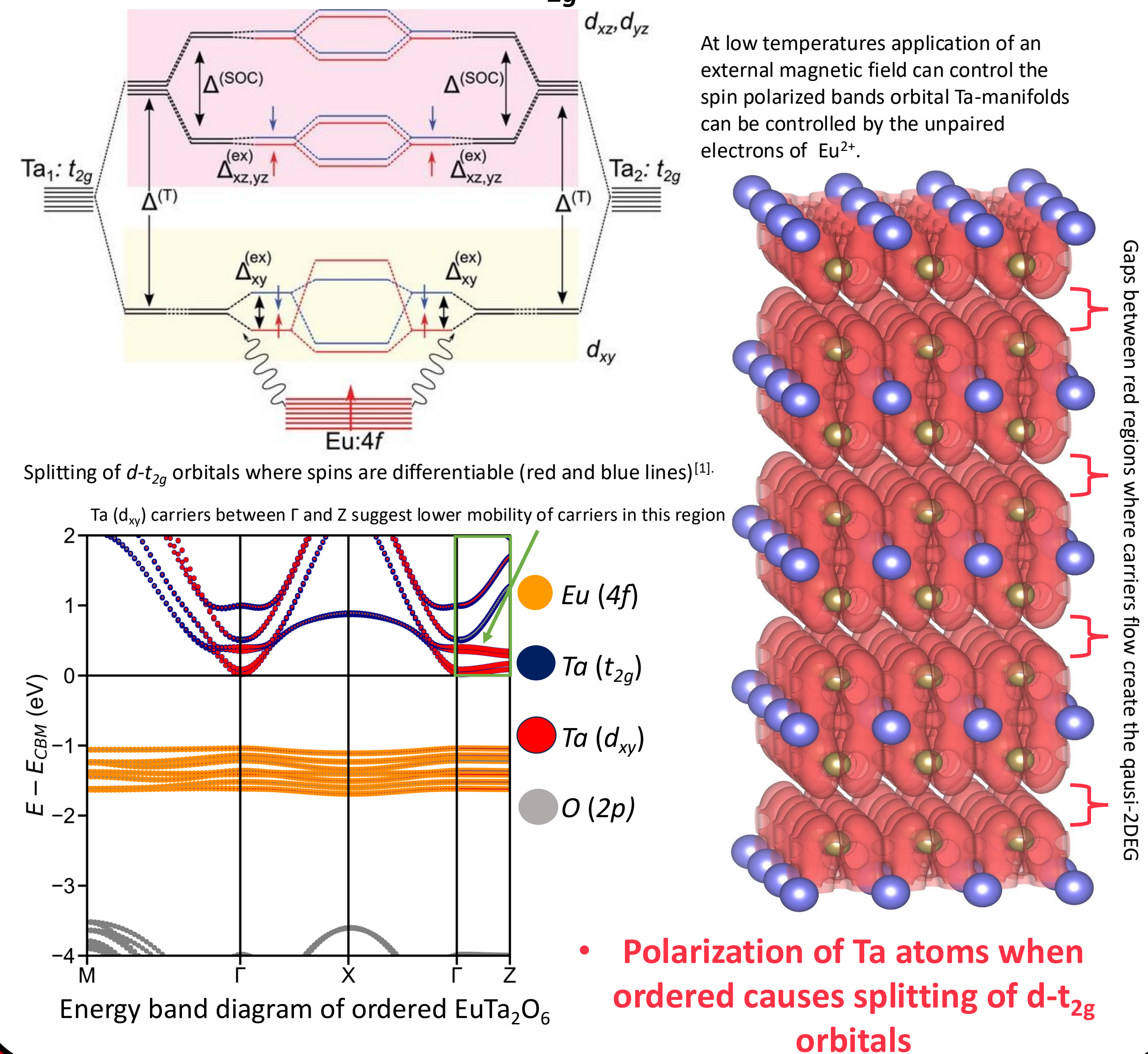
Lattice Constants of EuTa_2O_6	
$a = b$ (Å)	3.926
c (Å)	7.929
Ta-O (z)	1.906
Ta-O	1.977

The growth of $\text{Eu}_x\text{Ta}_{2-x}\text{O}_{6-x}$ can result in a range of ordering:

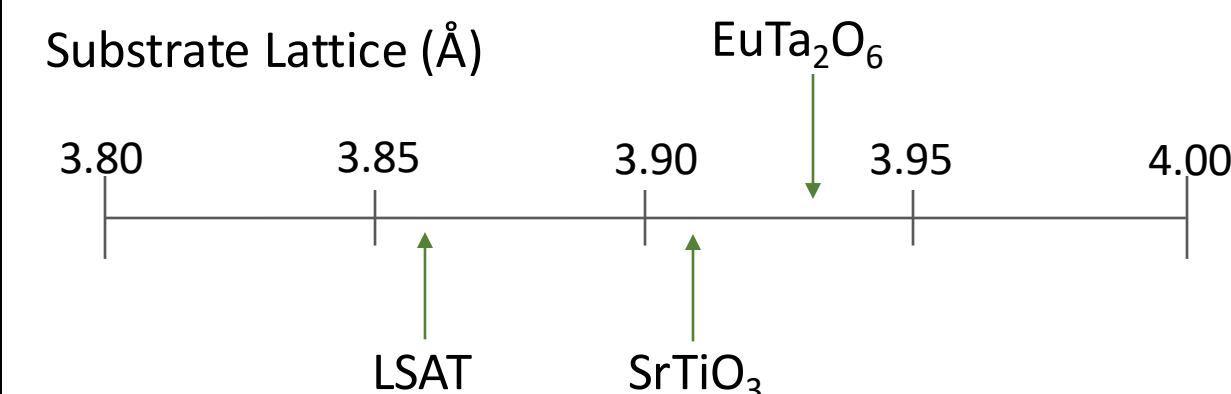
$X = 1$ being the **most ordered** structure with alternating layers of fully occupied and fully unoccupied Eu-sites along the c -axis

$X = 0.5$ to be the **most disordered** structure with only half occupied Eu-sites.

Splitting of the d - t_{2g} Ta orbitals by ordering



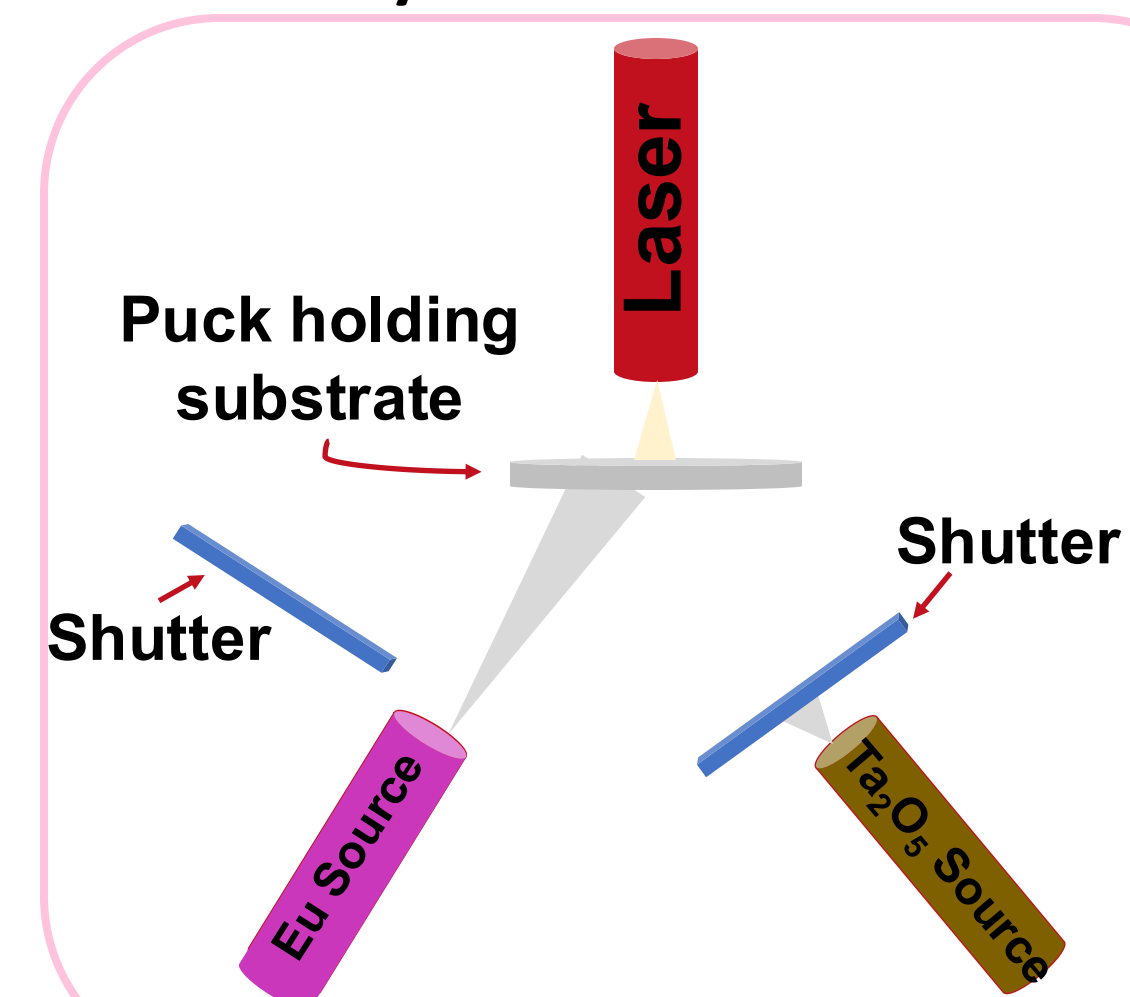
Application of compressive strain to control orientation and vacancy order in ETO



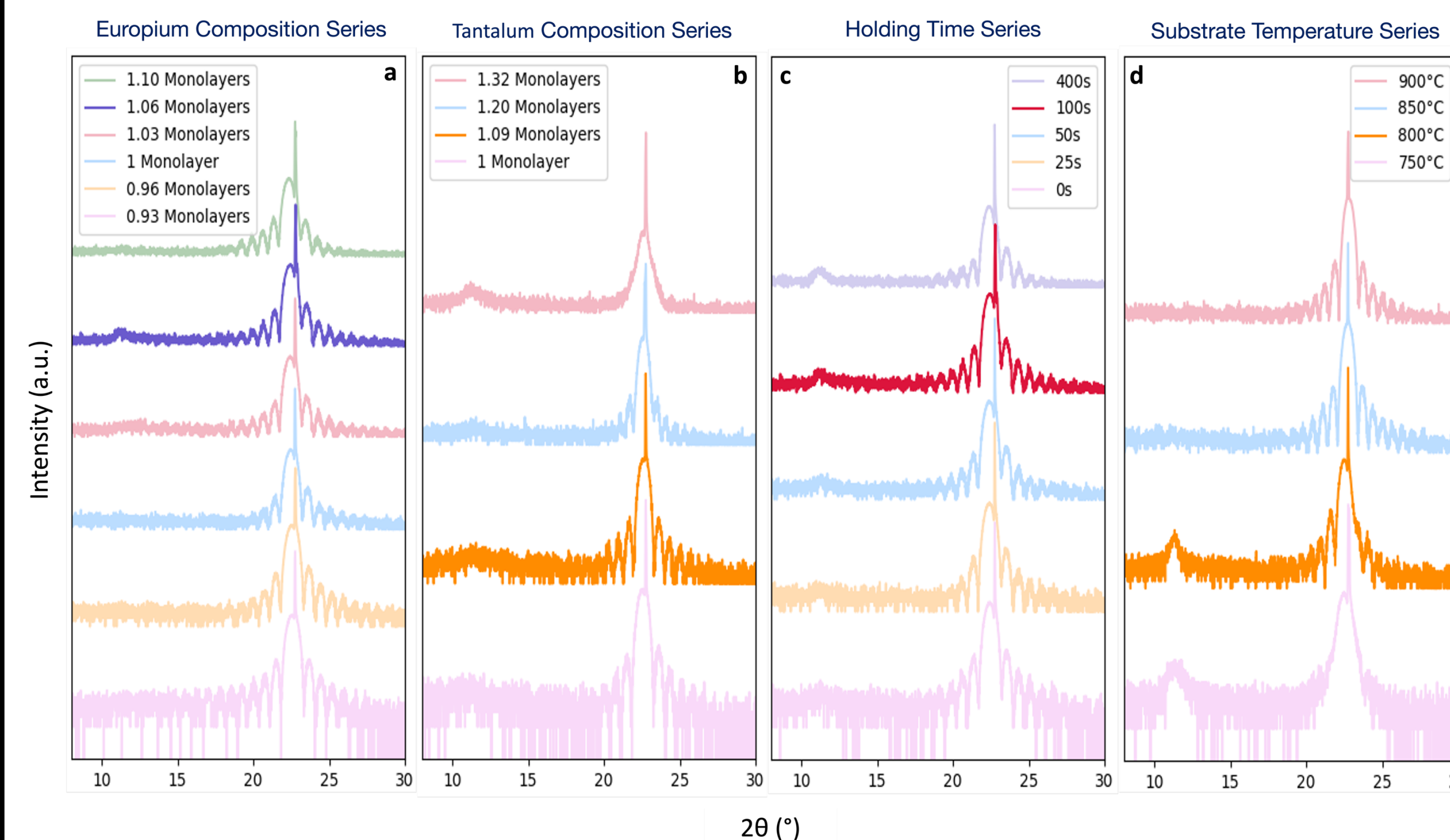
It has been shown in other materials that applying compressive strain on film by substrate can improve ordering of your crystal.

Using either LSAT or SrTiO₃ will apply this compressive strain as the lattice constant is smaller than ETO's $a=b$ lattice constant.

Growth with Molecular Beam Epitaxy by Shutter Method



Finding control over higher order structures by modulation of growth recipes

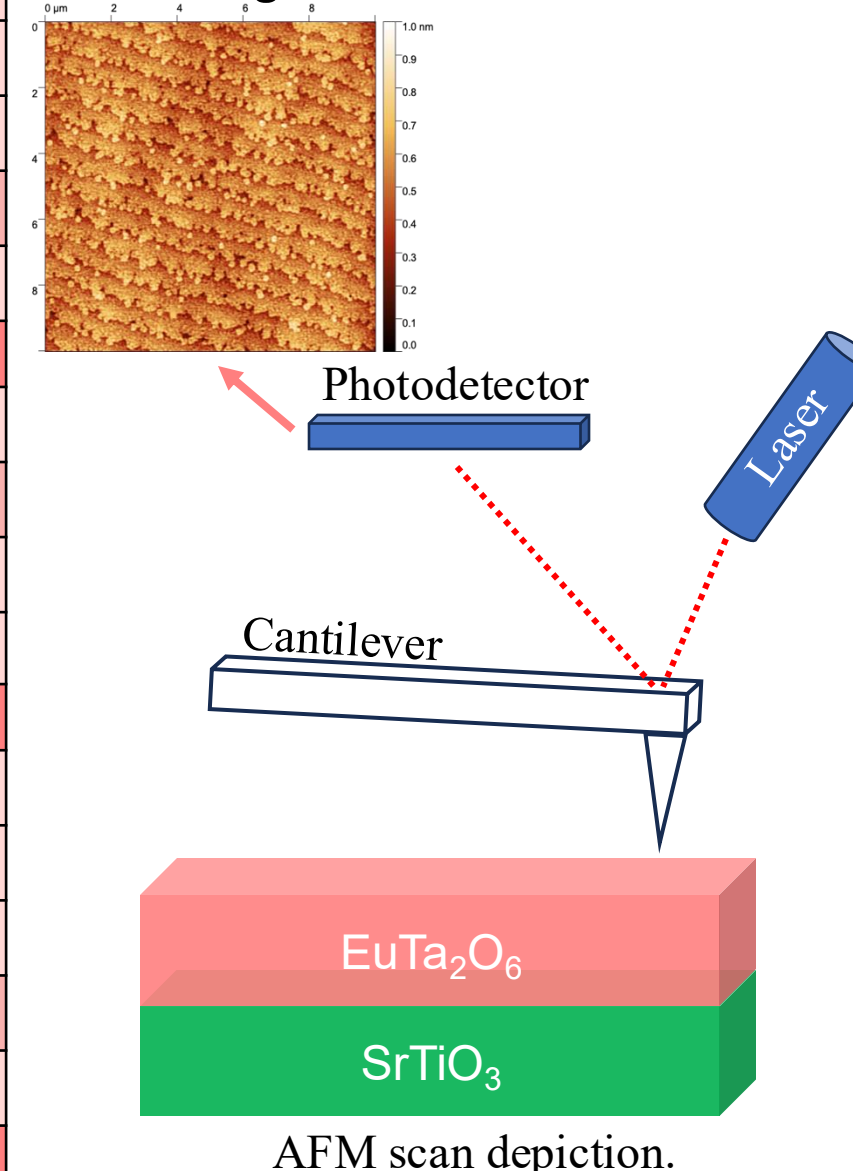


X-ray Diffraction scan series depict variation of growth parameters to determine optimal conditions for higher ordering in ETO. a) Europium composition series b) Tantalum composition series c) Holding time between unit cells series d) Substrate Temperature series

Atomic Force Microscopy rms roughness values for films in the series

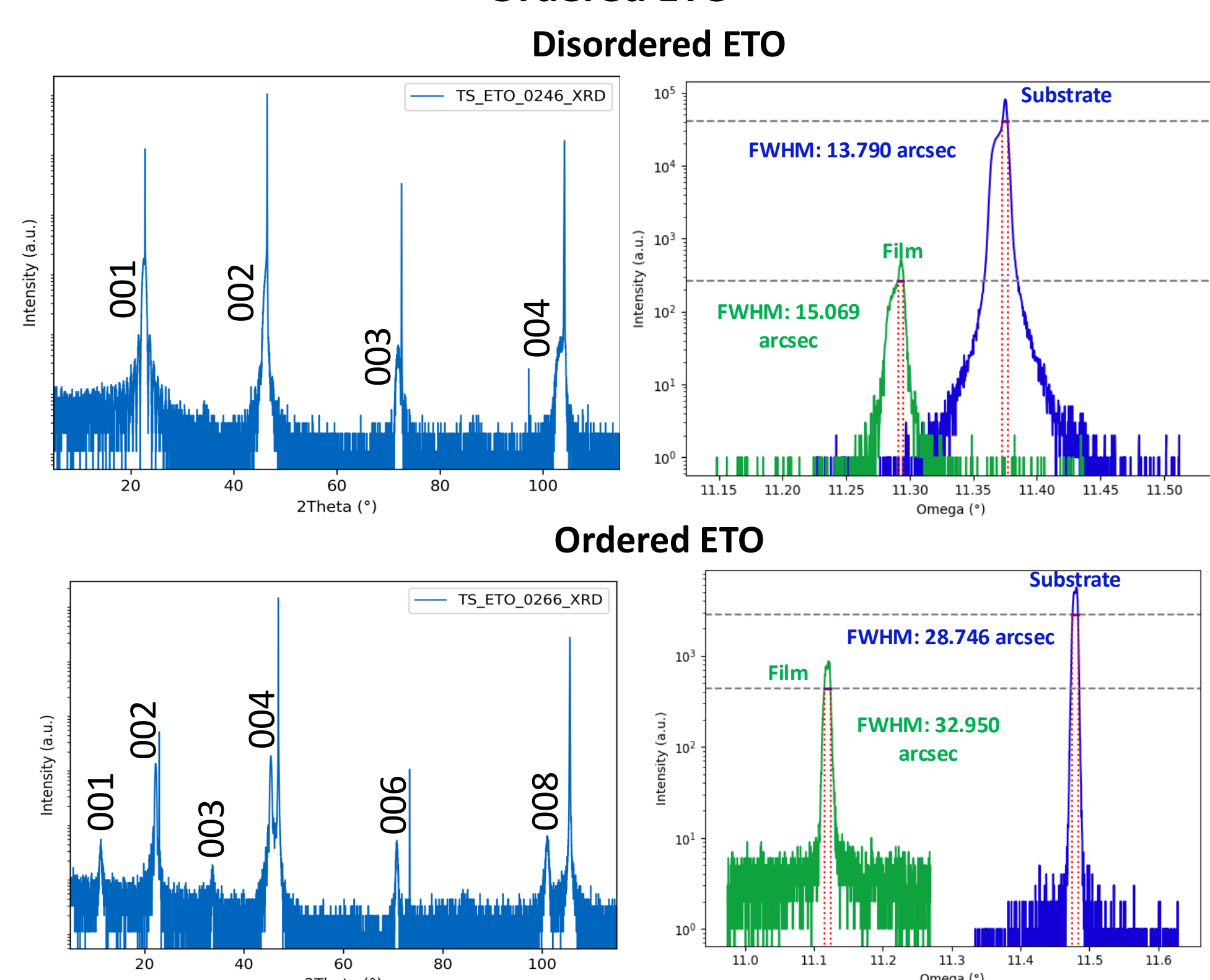
Series	Conditions	RMS Roughness (pm)
Europium	0.93 Monolayer	198.2
	0.96 Monolayer	232.7
	1.00 Monolayer	240.7
	1.03 Monolayer	205.8
	1.10 Monolayer	192.2
Tantalum	1.00 Monolayer	298.7
	1.09 Monolayer	173.4
	1.20 Monolayer	393.0
	1.32 Monolayer	794.4
Holding Time	0 seconds	180.1
	25 seconds	177.6
	50 seconds	190.9
	100 seconds	113.7
Substrate Temperature	900 °C	307.4
	850 °C	115.7
	800 °C	285.2
Highest order	750 °C	526.0

AFM scans revealed the rms (root-mean square) roughness is lower for the higher ordered conditions.



The 850°C substrate temperature reveals a high crystalline quality disordered film resulting in the low roughness.

XRD Shows High Crystalline Quality of both Disordered and Ordered ETO

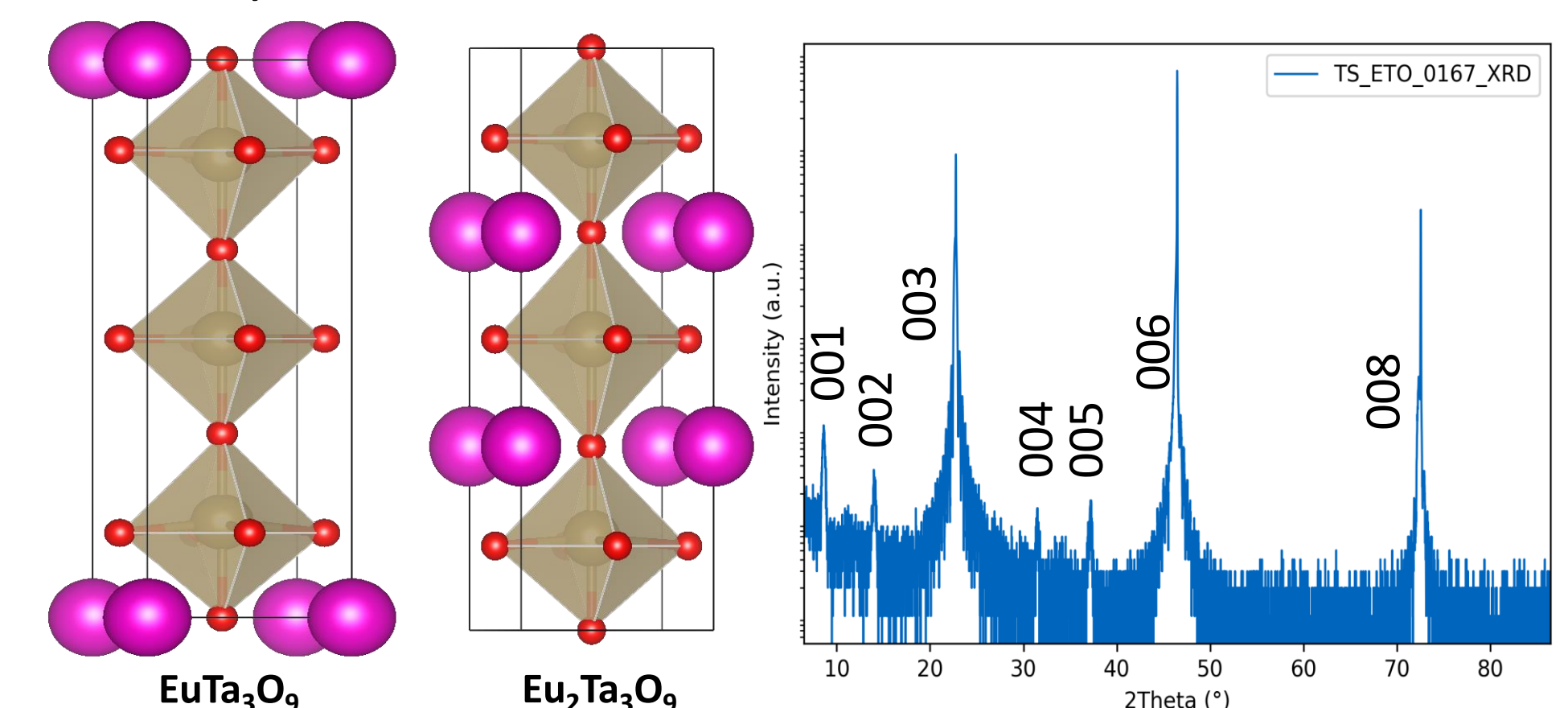


XRD scans (left) of disordered and ordered ETO with corresponding rocking curves (right) that show close full-width half max values of the substrate and film.

Conclusions and Future Plans

Successful control over which polymorph of $\text{Eu}_x\text{Ta}_{2-x}\text{O}_{6-x}$ is being grown by Molecular Beam Epitaxy, allowing exploration of the levels of ordering and the effect on the formation quasi-2DEG.

There has been some speculation of different A - B site stacking forming by X-ray Diffraction. Exploration of this possibility is underway.



Potential structures of ETO with an additional B-site layer.

XRD data shows two "ordering peaks", i.e., 001 and 002, before the fundamental peak, 003.

Acknowledgements

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References

[1] O. Dowinton, D. Maryenko, R. V. Belosludov, B.-J. Yang, M. S. Bahramy, *Adv. Funct. Mater.* 2023, 33, 2300995.